

UNITED STATES PATENT AND TRADEMARK OFFICE  
**CERTIFICATE OF CORRECTION**

PATENT NO. : 6,882,407 B2  
DATED : April 19, 2005  
INVENTOR(S) : Tadahiro Asaishi

Page 1 of 1

It is certified that error appears in the above-identified patent and that said Letters Patent is hereby corrected as shown below:

Column 1.

Lines 5-9, should be deleted and the following inserted therefor:

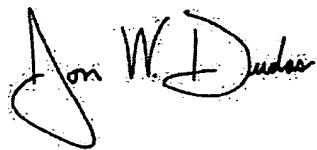
-- The present invention relates to an exposure apparatus suitable for manufacturing a device typified by, e.g., a semiconductor device or liquid crystal display device. --.  
Line 13, "apparatus" should read -- apparatus, --.

Column 7.

Line 20, "conformity" should read -- uniformity --.  
Line 27, "hundres" should read -- hundreds --.  
Line 59, "integarated" should read -- integrated --.

Signed and Sealed this

Fourth Day of October, 2005



JON W. DUDAS  
*Director of the United States Patent and Trademark Office*